ผลของลักษณะของฟิล์มบางไทเทเนียมไดออกไซค์ที่มีผลต่อปฏิกิริยาโฟโตคะตะไลติกรีคักชั้นของเฮกซะวาเลนซ์ โครเมียมโดยใช้ถังปฏิกรณ์แบบแผ่นตรึง



นางสาว อภิญญา ทิศาวิกาคสกุล

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EFFECT OF THIN FILM TITANIUM DIOXIDE CHARACTERISTICS ON PHOTOCATALYTIC REDUCTION OF CHROMIUM (VI) USING FIXED BED PHOTOREACTOR

Miss Apinya Tisavipaksakul

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อภิญญา ทิศาวิภาคสกุล : ผลของลักษณะฟิล์มบางไทเทเนียมไคออกไซค์ที่มีผลค่อปฏิกิริยาโฟโต คะตะไลติกรีคักชั้นของเฮกซะวาเลนซ์โครเมียมโดยใช้ถังปฏิกรณ์แบบแผ่นครึ่ง.

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งานวิจัยฉบับนี้ได้ศึกษาผลของลักษณะฟิล์มบางไทเทเนียมไคออกไซค์ที่ใช้ในการกำจัดเฮกชะวา เลนซ์โครเมียมในปฏิกิริยาโฟโตคะตะ ใลติกรีดักชันโดยใช้ถังปฏิกรณ์แบบแผ่นตรึงซึ่งมีจุดมุ่งหมายเพื่อหา สภาวะที่เหมาะสมที่สุดของฟิล์มบางไทเทเนียมไดออกไซด์ซึ่งเตรียมด้วยวิชีโซล-เจลสำหรับใช้ในถัง ปัจจัยที่ส่งผลกระทบต่อคุณสมบัติของฟิล์มบางไทเทเนียมไคออกไซค์ คือ การ ปฏิกรณ์แบบแผ่นครึ่ง เค็มอะซีคิลอะซีโคนเพื่อช่วยในการปรับสภาพผิวของฟิล์มบาง อณหภมิที่ใช้ในการเครียมแผ่นฟิล์ม ไทเทเนียมไดออกไซด์ จำนวนรอบของการจุ่มเคถือบแผ่นฟิล์ม และความยาวคลื่นที่เหมาะสมในการทำ อัตราส่วนที่ใช้ในการเตรียมสารละลายไทเทเนียมไคออกไซค์ คือ ไทเทเนียมไคออกไซค์: ปฏิกิริยา เอธานอล: กรคใชโครคลอริก: อะซีติล อะซีโตน เท่ากับ 1:30:0.5:1 ตามลำคับ จากการวิจัยพบว่า อะซีดิลอะซีโตนเป็นสารที่ช่วยป้องกันการเกิดรอยแตกบนผิวของฟิล์มไทเทเนียมไดออกไซด์ และยังช่วย เพิ่มประสิทธิภาพในปฏิกิริยาโฟโตคะตะไลดิกรีคักขัน สภาวะที่เหมาะสมที่สุดในการเตรียมแผ่นฟิล์ม ไทเทเนียมไดออกไซด์บนสเตนเลส คือ เผาที่อุณหภูมิ 500°C และจุ่มเคลือบฟิล์ม 3 รอบ ซึ่งเป็นสภาวะที่ ให้ประสิทธิภาพในการกำจัดโครเมียม (+6) คีที่สุด เพราะที่สภาวะนี้จะให้ผลึกอนาเทสมากที่สุดและมี ขนาคของผลึกเล็กที่สุด ทั้งนี้การรวมตัวของอิเลกตรอนและโฮล จะเกิดขึ้นเมื่อมีการถุ่มเคลือบ 4 รอบขึ้น ไป ซึ่งจะทำให้ฟิล์มมีความหนาแน่นมากกว่า 91 นาโนเมตร ความยาวคลื่นที่เหมาะสมในการทำปฏิกิริยา คือ ที่ความยาวคลื่น 380 นาโนเมตร เนื่องจากเป็นความยาวคลื่นที่ให้พลังงานที่เหมาะสมสำหรับฟิล์มบาง ไทเทเนียมไดออกไซด์ ในการศึกษาพบว่าปฏิกิริยาโฟโตคะตะไลติกรีดักชั้นของโครเมียม (+6) ของทุกการ ทคลองเป็นไปตามกฎ zero-order reaction และขังมีการศึกษาค่า kinetic coefficient (k) ด้วย

สาขาวิชาการจัดการสิ่งแวดล้อม ปีการศึกษา2548 ลายมือชื่อนิสิต Aphyer Tisavipales ใจ ลายมือชื่ออาจารย์ที่ปรึกษา Leptony rat

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APINYA TISAVIPAKSAKUL : EFFECT OF THIN FILM TITANIUM DIOXIDE CHARACTERISTICS ON PHOTOCATALYTIC REDUCTION OF CHROMIUM (VI) USING FIXED BED PHOTOREACTOR. THESIS ADVISOR: ASST. PROF. DR. PUANGRAT KAJITVICHYANUKUL, PH.D., 110 pp. ISBN 974-53-2876-6.

This research focused on the effect of thin film TiO, characteristics on chromium (VI) removal in the photocatalytic reduction using a fixed bed photoreactor. The goal of this work was to verify the optimum synthesis condition of nanocrystalline TiO₂ thin layers derived from the sol-gel process to be used in the fixed bed photoreactor. The factors influencing the thin layers properties were the addition of acetyl acetone used as an additive, the calcination temperatures, the number of coating cycles and the appropriate wavelengths. The mole ratio of TiO₂ was titanium (IV) butoxide: ethanol: HCl: acetyl acetone at 1: 30: 0.5: 1, respectively. From this work, It was found that acetyl acetone prevented the cracking of the surface morphology as shown in the SEM micrographs and gave the high efficiency of photocatalytic reduction. The optimum condition to produce the immobilized TiO₂ on stainless steel was found at 500 °C calcination temperature and the 3-coating cycles which gave the highest photocatalytic activities due to the highest amount of the anatase phase and smallest size of nanocrystalline TiO2. Moreover, the recombination of electrons and holes was found at 4coating cycles in which the thickness higher than 91 nm. The appropriate wavelength was found at 380 nm provided the optimum energy to the thin film TiO₂. Photocatalytic reduction of Cr (VI) in all experiments followed zero order pattern and the kinetic coefficients in all cases were also reported in this work.

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NOMENCLATURE

AOPs = advanced oxidation processes

Cr (III) = trivalent chromium

Cr (VI) = hexavalent chromium

FeO = ferrous oxide

OH = hydroxyl radical

OH = hydroxide ion

 TiO_2 = titanium dioxide

UV = ultraviolet